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An intermetallic powder-in-tube approach to increased flux-pinning in Nb₃Sn by internal oxidation of Zr

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Abstract We report on the development of multifilamentary Nb₃Sn superconductors by a versatile powder-in-tube technique (PIT) that demonstrates a simple pathway to a strand with a higher density of flux-pinning sites that has the potential to increase critical current density beyond present levels. The approach uses internal oxidation of Zr-alloyed Nb tubes to produce Zr oxide particles within the Nb₃Sn layer that act as a dispersion of artificial pinning centres (APC). In this design, SnO₂ powder is mixed with Cu₅Sn₄ powder within the PIT core that supplies the Sn for the A15 reaction with Nb1Zr filament tubes. Initial results show an average grain size of ~38 nm in the A15 layer, compared to the 90-130 nm of typical APC-free high- J_c strands made by conventional PIT or Internal Sn processing. There is a shift in the peak of the pinning force curve from H/H_{irr} of ~0.2 to ~0.3 and the pinning force curves can be deconvoluted into grain boundary and point-pinning components, the point-pinning contribution dominating for the APC Nb-1wt%Zr strands.

1. Introduction

Multifilamentary Nb₃Sn strands have a high manufacturing maturity with very large quantities of low hysteresis loss wires produced for the ITER project (600 t) [1] and high current density strands being procured for the High Luminosity (HiLumi) upgrade to the Large Hadron Collider (4.8 t MQXF)[2,3]. For applications that require magnetic fields above 15 T, HTS conductors like Bi-2212 can outperform Nb₃Sn [4] but their cost is still prohibitive for future large scale applications such as the High Energy LHC (HE-LHC) [5] or the Future Circular Collider [6] both of

which envision ~16 T dipole operation [7]. However, there are significant challenges to developing Nb₃Sn for practical use in an accelerator at such high fields because the critical current density, J_c , target specification of 2300 A/mm² (1.9 K, 16 T) or 1500 A/mm² at 16 T, 4.2 K [8] is ~50% higher than that of the present HiLumi procurement [9], which is the highest field and highest J_c accelerator application so far. Improvements in conductor performance are required to provide operating margin, but any performance increase that can lead to a reduction in cost is also highly desirable because the FCC conductor as currently specified is estimated to represent 50% of the magnet cost

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[7]. Although recent developments in the understanding and optimization of Nb₃Sn strand heat treatments have suggested room to improve the critical current density in existing internal Sn [10] and PIT [11] conductors, achieving the FCC specification is a challenge that almost certainly requires enhanced vortex pinning too.

In conventional Nb₃Sn conductors, vortex pinning strength is determined by the grain boundary density [12]. However, a typical grain diameter of ~100 nm is much greater than the ~12 nm fluxoid spacing at 16 T, making the pinning efficiency low. Consequently, there have been a number of attempts to introduce additional pinning sites including the powder metallurgical incorporation of Ta ribbons [13,14], Cu [15,16], Ag [17], and films doped with Ti or Y [18] and Y, Sc, Dy, Al₂O₃, or Ti [19]. However, none of these attempts has been developed into a successful multifilamentary wire. Internal oxidation of Zr-doped Nb was successfully developed for tapes at General Electric (GE) [20]. In the GE tape process, liquid Sn was reacted with Nb foil above 900 °C but the tape critical current density was limited by the resulting large grain size. Doping the Nb tape with Zr and oxygen reduced the A15 grain size to approximately 50 nm (which is ~ half that of modern solid-state reactions). Their TEM studies showed that this process produced coherent ZrO₂ precipitates throughout the Nb₃Sn grains. They also concluded that the slow coarsening of the Nb₃Sn grain size was a result of ZrO₂ precipitates dissolving in shrinking grains and then re-precipitating at the grain boundaries of growing A15 grains. Zeitlin *et al.* [21] attempted to adapt this approach to conventional filamentary internal Sn Nb₃Sn wires by adding SnO₂ to the Sn core of Nb-1wt%Zr (Nb1Zr) filament tubes and they did produce some grain refinement at high temperatures. Further progress was made when Xu *et al.* [22] concluded that the attempts to adapt the GE technique to internal Sn wires had not been successful because the Cu matrix around each filament had less affinity for oxygen than the Sn and thus had prevented oxygen diffusion into the Nb1Zr. Using a Sn-in-Tube architecture Xu *et al.* inserted a SnO₂ layer between the Cu sleeve that normally surrounds the Sn-Cu core and the Nb1Zr matrix and were able to refine the Nb₃Sn grain

size to as small as 43 nm. However, scale-up of this approach is challenging because of the required oxide layer between the sleeve and tube. In this paper we demonstrate a potential simplification of this fabrication complexity with a Powder-in-Tube process in which powder mixtures of Cu₅Sn₄ and SnO₂ are inserted into Nb1Zr tubes. We show that this design provides a flexible alternative artificial pinning centre (APC) vehicle for nano-precipitation of ZrO₂ in the A15 layer.

2. Methods

2.1 Wire Fabrication

Cu₅Sn₄ (η phase) was used as the Sn powder source rather than the NbSn₂ powder of the conventional ECN PIT design [23] because it is less costly and easier to make [24] (the Nb in the NbSn₂ does not contribute to the small-grain A15 phase, whereas the Cu in the Cu₅Sn₄ is required for the low temperature formation of Nb₃Sn). The Cu₅Sn₄ is made by mixing Sn and Cu powders with a starting composition of 59.9 wt.% Sn (an atomic ratio of Cu₅Sn₄ [25] and heat-treating them below 400 °C. A significant difference between NbSn₂-based PIT designs and this approach is that the η phase melts at 415 °C, well below the heat treatment temperatures used for Nb₃Sn formation. The Cu₅Sn₄ intermetallic is ball milled and then jet milled to a particle size that was typically 99% < 3 μ m (top size of 6 μ m), so that the maximum particle size is significantly smaller than the ultimate filament core size to maintain composite stability during wire drawing. SnO₂ powder mixed with the Cu₅Sn₄ supplies the oxygen. For the composites supplied to BNL, two ratios of SnO₂:Cu₅Sn₄ were used, denoted “H” and “S”, with the SnO₂ content in mixture “H” almost double that in “S”. Wires with undisclosed SnO₂:Cu₅Sn₄ ratios were supplied to FSU and are described as compositions “SnO₂2X”, “SnO₂1X” and “10SnO₂” to distinguish them from the BNL billet compositions. The mixed powder was packed into Cu-clad Nb-1wt%Zr tubes, which were then drawn to a restack size. Two multifilamentary composite designs were fabricated from these monocoresh; a 7-filament hexagonal stack (figure 1a) and a 120 filament octagonal assembly (figure 1b that was largely studied at BNL) that allows for the introduction of interfilamentary strengthening

Table I. Summary of PIT wires tested at BNL with Heat Treatment (HT) conditions

BNL Run	HT Temp, °C	HT Time, h	Cu/Non-Cu Ratio	Filaments	Filament Diameter, μ m	Billet ID	SnO ₂ :Cu ₅ Sn ₄ and Comments	Wire Dia., mm
3991	625	300	1.0	120	59	APC 550	SnO ₂ (“S”)	0.91
3993	650	200	1.0	120	59	APC 550	SnO ₂ (“S”)	0.91
3994	650	200	1.0	120	59	APC 550	SnO ₂ (“S”)	0.91
4051	632	200	1.0	120	51	APC 555	500 °C/24h+HT, SnO ₂ (“H”)	0.79
4133	630	100	1.0	120	59	APC 555	SnO ₂ (“H”)	0.91

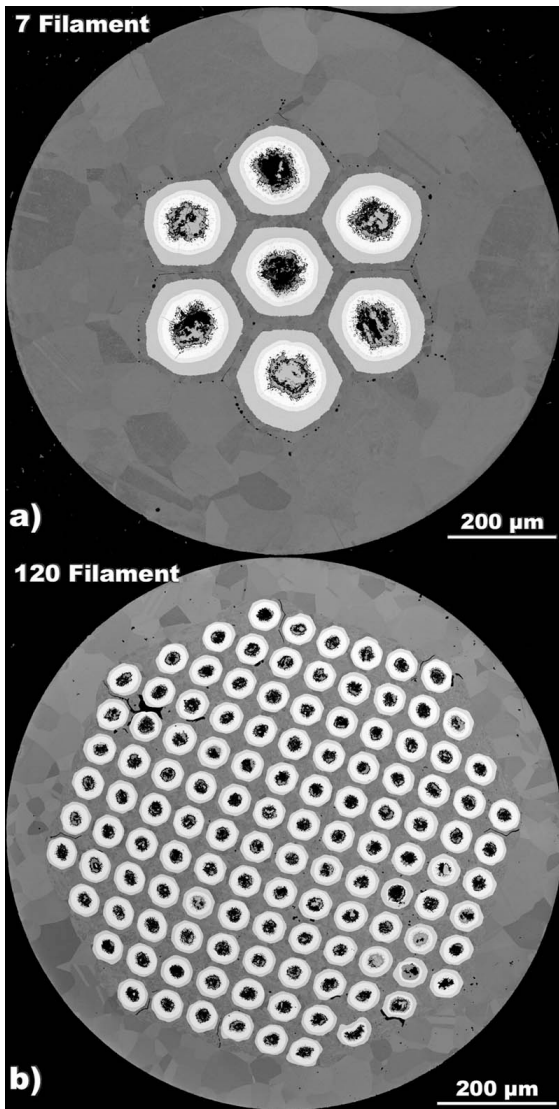


Figure 1. FESEM-BSE images of a) the reacted 7-filament (300h/625°C) and reacted 120 filament (200h/640°C) PIT composites.

elements [24]. The assembled multifilamentary composites were drawn to final diameters ranging from 1 to 0.5 mm. The strands supplied to BNL are summarized in table I.

2.2 Metallography

Short lengths of heat treated wires were provided by SupraMagnetics for microstructural and microchemical evaluation. The samples were polished in transverse cross-section and imaged using a Zeiss 1540EsB CrossBeam Field Emission Scanning Electron Microscope (FESEM). Microchemical analysis was performed in the FESEM using an EDAX Apollo XP SDD detector energy dispersive x-ray detector.

2.3 Magnetization Measurements

Magnetization measurements were performed on the short samples (~5 mm) using a 14 T Oxford Instruments dedicated

Vibrating Sample Magnetometer (VSM) capable of operation at variable temperatures from 2 K to above T_c . The critical current density was estimated by the Bean model and the pinning force and Kramer curves were analyzed similarly to the transport data (see ahead).

2.4 Transport Measurements

Unreacted 120 filament wires were supplied to BNL for barrel heat treatment (HT) and measurement at magnetic fields up to 15 T. The ramp up to the HT reaction temperature was typically at a rate of 25°C/h. Transport measurement was on a standard ITER with the central 7 turns in a uniform field, using the 0.1 µV/cm criterion and a measured sample length of 0.7 m. The data were analyzed by fitting the volume flux-pinning curve $F_p(H)$ (with self-field correction) to the generic expression $F_p(H) = C \cdot h^p (1 - h)^q$, where C is a constant, $h = H/H_{irr}$, and H_{irr} is the irreversibility field. Standard process Nb₃Sn conductors without point pins are generally fit well by $p = 0.5$ and $q = 2.0$, which is essentially the Kramer fit [26] with B_{c2} being appropriately replaced by the Kramer field H_K extrapolation from ~10 to 15 T to define the irreversibility field at which J_c becomes zero.

3. Results

3.1. Microstructures

3.1.1. General Observations. The multifilament wires were difficult to draw to final size without breakage and even unbroken wires had broken filaments. In figure 2a we show five cross-sections from the same ~50 mm length of a 120 filament composite after a reaction heat treatment of 200 h

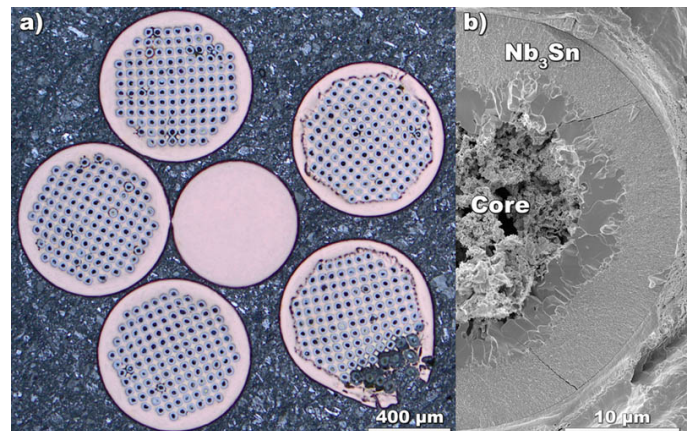


Figure 2. a) Light microscope image of five transverse cross sections from a 0.7 mm diameter 120 filament Nb1Zr+SnO₂ sample after a 200h/650°C heat treatment. These cross-sections showing Sn leakage and Sn burst are typical of the drawing issues experienced with these strands. b). FESEM-in-lens secondary electron image of a good filament from the same strand fractured to show the grain size. The small-grain Nb₃Sn layer is labelled.

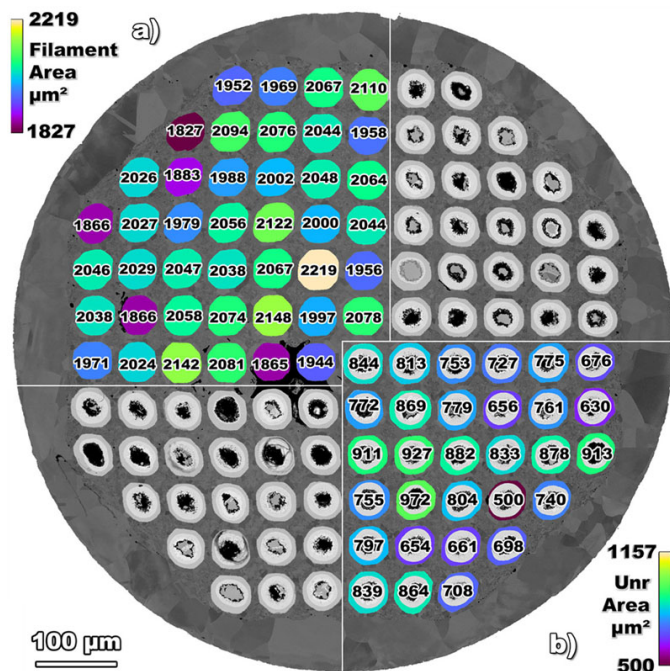


Figure 3. FESEM-BSE image of a 120 filament Nb1Zr+10SnO₂ sample after a 24h/500°C + 200h/650°C two-step heat treatment overlaid with quantitative analyses of the filament cross-sections. The top left quadrant analysis (a) indicates total area measurements of the filaments, whereas the bottom right quadrant analysis (b) indicates the residual Nb1Zr filament tube areas after the A15 reaction. The significant variation of un-reacted tube-cross-sectional areas is an indicator of pre-existing tube non-uniformities after drawing and prior to reaction.

at 650°C. A significant number of filament tubes have been breached and in one case there was Sn burst to the outside.

Nevertheless, as shown in figure 2b, an extensive small-grain Nb₃Sn layer was found after reaction in the unbreached filaments of this strand.

The difficulty in drawing the composites to final size was attributed to a difficulty in obtaining Nb1Zr tube of the correct size and quality. Figure 3, is a cross-sectional BSE image of a 120 filament Nb1Zr+SnO₂ sample after a 24h/500°C + 200h/650°C two-step heat treatment that we have color-coded to contrast the total filament areas with the residual Nb1Zr areas after the A15 reaction. The quantitative image analysis indicated that the overall filament cross-sectional areas (as indicated in figure 3a) were fairly uniform, between 1800-2200 μm². The residual un-reacted Nb1Zr areas were much more variable, with the un-reacted areas differing by almost a factor of 2 from 500 μm² to 1100 μm². This large disparity is one indication of non-uniform deformation, and thinning of the Nb1Zr tubes during drawing as well as local variation induced by Sn loss from locally thinned and broken tube walls.

The samples were fractured to reveal the grain size as Nb₃Sn typically fractures along the grain boundaries. On these grain boundary fracture surfaces, we observed precipitate-like features similar in size and distribution to those observed by Xu *et al.* using TEM [27]. These features, assumed to be ZrO₂ precipitates, ranged in size from 5-15 nm in diameter but they were too small to confirm as ZrO₂ by compositional analysis in the FESEM. The oxidation of Zr is thermodynamically favoured over Nb, Sn and Cu and Rumaner *et al.* found by electron diffraction in TEM that the

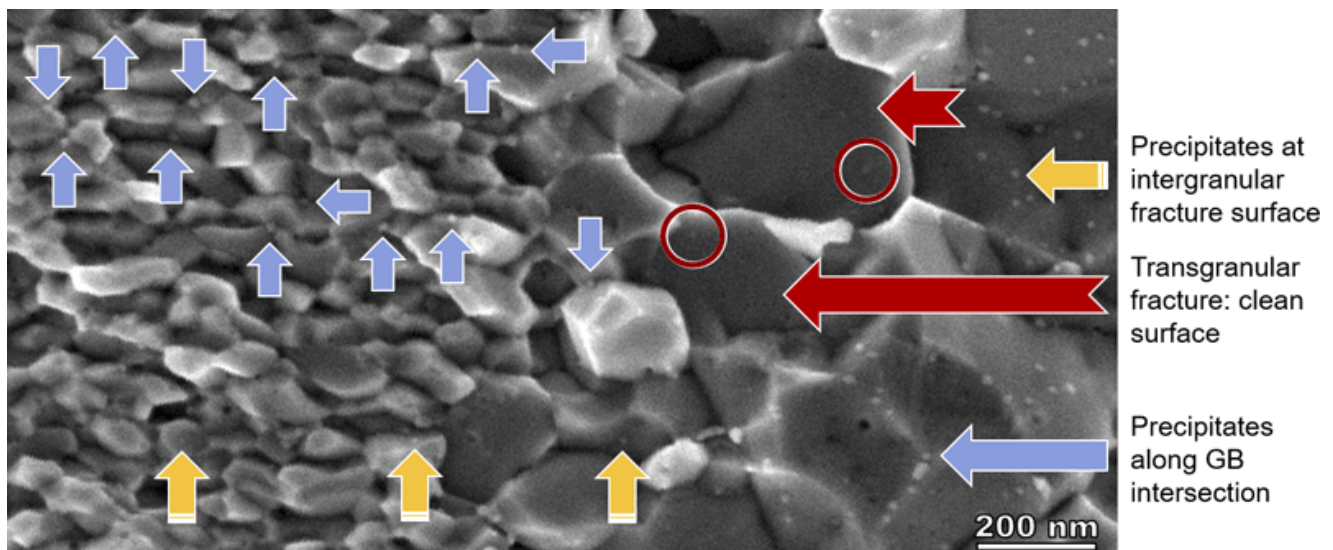


Figure 4. FESEM-in-lens secondary electron image of fracture surface at the interface between the large and small-grain regions in a representative region of a 120 filament Nb1Zr+“10SnO₂” sample after a 300h/630°C heat treatment. Precipitate-like features that we assume to be ZrO₂ are most commonly observed at grain boundary intersections (blue arrows) and less commonly at intergranular surfaces (orange arrows). For fractures through the grains (red arrows) there were no surface features but occasionally faint precipitate-scale contrast (red circles) that might indicate fracture through interior precipitates.

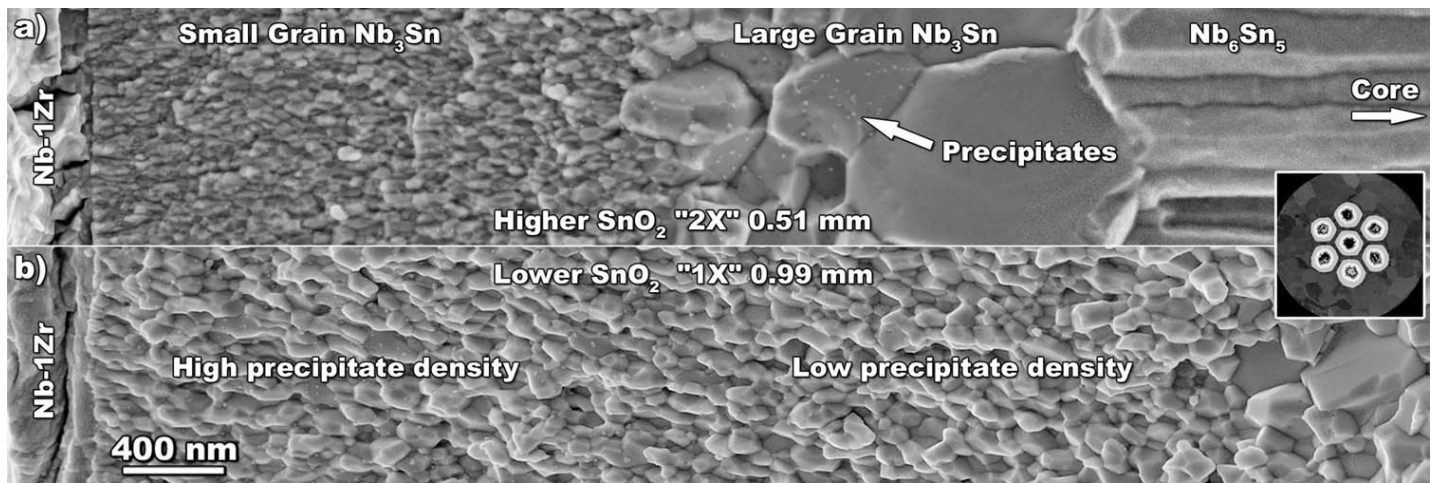


Figure 5. FESEM-in-lens secondary electron images of fracture surfaces of the small-grain Nb₃Sn layers in two 7-filament (inset) composites with different Cu₅Sn₄:SnO₂ ratios. Both samples were heat treated at 625 °C for 300 h, a) is at a wire diameter of 0.51 mm with higher ratio “SnO₂2X” and b) at 0.99 mm diameter with lower ratio “SnO₂1X”. The higher SnO₂:Cu₅Sn₄ ratio produced an A15 grain diameter that was ~ half the lower ratio “SnO₂1X” sample. We did not observe precipitate contrast in the transgranular fractures.

precipitates in their Nb-1Zr experiments (by a quite different approach and using high temperatures where the Zr is more mobile) were monoclinic ZrO₂ [20]. We did not observe particles in fractured surfaces in a Ta-doped PIT sample using the same Cu₅Sn₄ powder but no SnO₂ or Zr [25], however, fracture performed elsewhere of Nb₃Sn that was not designed for oxidation has produced surface particulates of similar size and contrast [28,29]. An example of the precipitates at the interface between the large and small grain A15 regions is shown in figure 4. The precipitates are sparsely distributed with rarely more than one precipitate per grain boundary segment in the small-grain regions. Most commonly, the precipitates are observed at grain boundary intersections (some examples are indicated by the blue arrows in figure 4). Less frequently, the precipitates are observed at grain boundary surfaces (as indicated by the orange arrows in figure 4). In figure 4 we also show some large grains (red notched arrows) that have fractured through the grains rather than at the grain boundaries, and in these we see no surface precipitates. There is, however, some faint contrast on the scale of the ZrO₂ precipitates that might suggest that the fracture has sliced through precipitates.

3.1.2 Cu₅Sn₄:SnO₂ ratio

In figure 5 fracture surfaces from two 7-filament composites with different Cu₅Sn₄:SnO₂ ratios but the same heat treatment (300h/625 °C) are contrasted. Composition “SnO₂2X” (figure 5a), is higher in SnO₂ and produces a much finer (<30 nm diameter near the Nb1Zr interface) A15 grain size than composition “SnO₂1X” (figure 5b). However, there is a clear grain size gradient with the grain diameter becoming smaller towards the Nb1Zr interface (outer edge of reaction front). However, the small grain layer is ~ half

the thickness for lower SnO₂ “SnO₂1X” strand. This might be related to the smaller strand diameter (0.51 mm compared with 0.91 mm) or that the reaction is proceeding slower. The precipitates also appear to be smaller for the higher SnO₂ ratio sample. All the samples had an interior layer of much larger A15 grains, as is found for conventional PIT Nb₃Sn wire. As indicated in figure 5b, closer to the core in the low-SnO₂ sample, the precipitate density is greatly reduced, suggesting a depleted oxygen supply in the low SnO₂ sample and inability to convert all the Zr to ZrO₂. The area-equivalent A15 grain diameter for the low-SnO₂ sample increased from ~77 nm at the Nb-1Zr interface to ~86 nm at the small-grain:large-grain interface. Both samples have a thick Nb₆Sn₅ layer adjacent to the large-grain Nb₃Sn layer. This thick interior layer of Nb₆Sn₅ is effectively a trapped Sn supply because bulk diffusion of Sn through Nb₃Sn is orders of magnitude slower than along grain boundaries [30] and the large grains offer sparse outward diffusion paths for the Sn. Note that, unlike conventional PIT Nb₃Sn which uses NbSn₂ powder in the core as the Sn source, in this SupraMagnetics Cu₅Sn₄ core design all the Nb for the Nb₃Sn and Nb₆Sn₅ phases is supplied by the Nb1Zr tube.

In these 7-filament composites the small-grain Nb₃Sn area was only 7.1% of the filament cross-section for the sample in figure 5a and 9.9% for the sample in figure 5b compared with ~40% of the cross-section for fully optimized accelerator quality PIT Nb₃Sn strands [11,31].

3.1.3 Microstructural Gradients The A15 grain size gradient in figure 5a is quantified in figure 6 in terms of area equivalent grain diameter (the diameter calculated from the

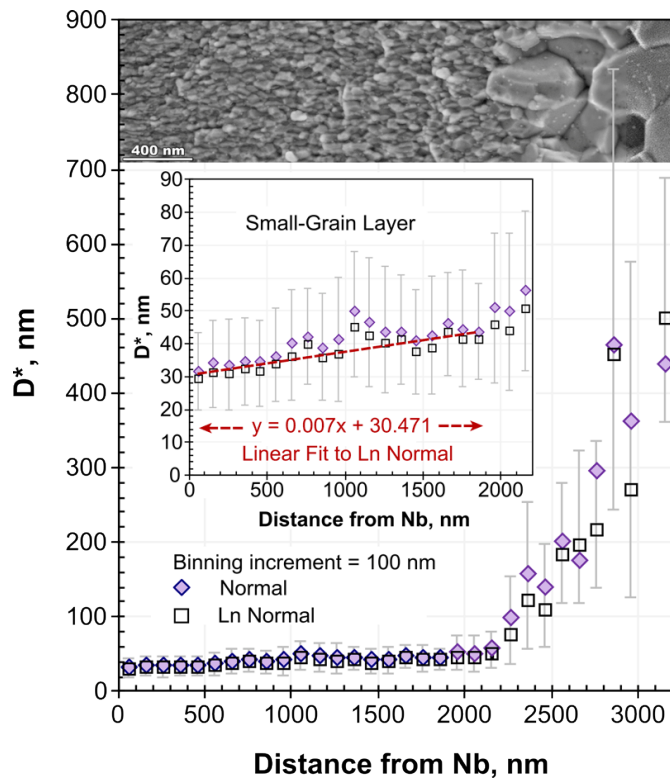


Figure 6. Area equivalent grain diameter variation with distance from the unreacted Nb1Zr interface for the high SnO₂:Cu₅Sn₄ composition “SnO₂2X” 7-filament strand in figure 5a. The size distribution is log-normal but both log-normal and normal averages for each bin are applied for comparison with other published data. The least-squares linear fit is applied to the log-normal data across the small grain range indicated. Error bars show $\pm$ one sample standard deviation based on log-normal statistics for each bin.

cross-section area assuming a circular cross-section). The A15 grain diameter is as small as 30 nm near the unreacted Nb1Zr interface and rises to a little over 40 nm near the original growth front neighbouring the large-grain region. The error bars show the log-normal standard deviations. Both values are much smaller than the ~90-150 nm size in conventional Zr-free A15 wires.

The impact on vortex pinning should be clearer when plotted in terms of grain boundary density, as is shown in figure 7, which increases by about 40% towards the outer edge of the reaction front. Because the grain size of the last A15 to form is smaller than that at the original core/Nb1Zr interface, it appears that some grain growth occurs as the A15 reaction front penetrates into the tube.

In figure 8 we plot the Nb₃Sn grain aspect ratio against distance from the Nb1Zr tube interface. We find a very constant aspect ratio across the fine grain region. A low Sn content as occurs at the Nb-A15 interface is often associated with an increase in A15 grain aspect ratio so this result is

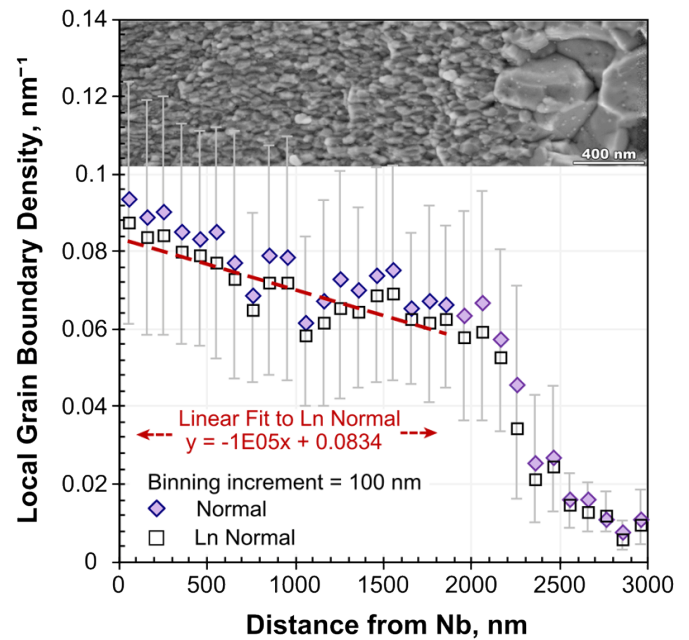


Figure 7. Decrease of Nb₃Sn grain boundary density with increasing distance from the reaction front at the Nb1Zr interface for the high SnO₂:Cu₅Sn₄ composition “SnO₂2X” 7-filament strand in figure 5a. The size distribution is log-normal but the mean of both log-normal and normal for each bin are presented. The least-squares fit is applied to the log-normal data across the small grain size range indicated. Error bars show $\pm$ one sample standard deviation based on log-normal statistics for each bin.

consistent with the uniform compositions reported in figure 9a and b. The ZrO₂ precipitates may, however, also play a

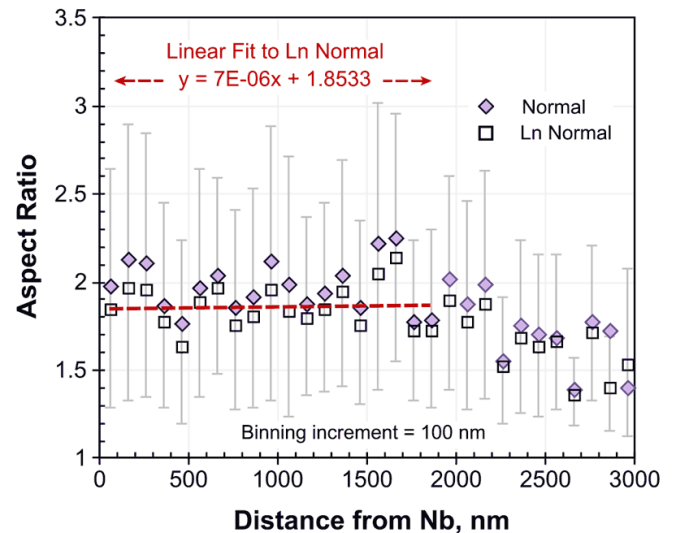


Figure 8. The aspect ratios for the Nb₃Sn grains as a function of distance from the unreacted Nb1Zr interface for the high SnO₂:Cu₅Sn₄ composition “SnO₂2X” 7-filament strand in figure 5a. The least-squares fit indicates that the aspect ratio is remarkably uniform across the small-grain A15 layer. The least-squares fit is applied to the log-normal data across the small grain range indicated. Error bars show $\pm$ one sample standard deviation based on log-normal statistics for each bin.

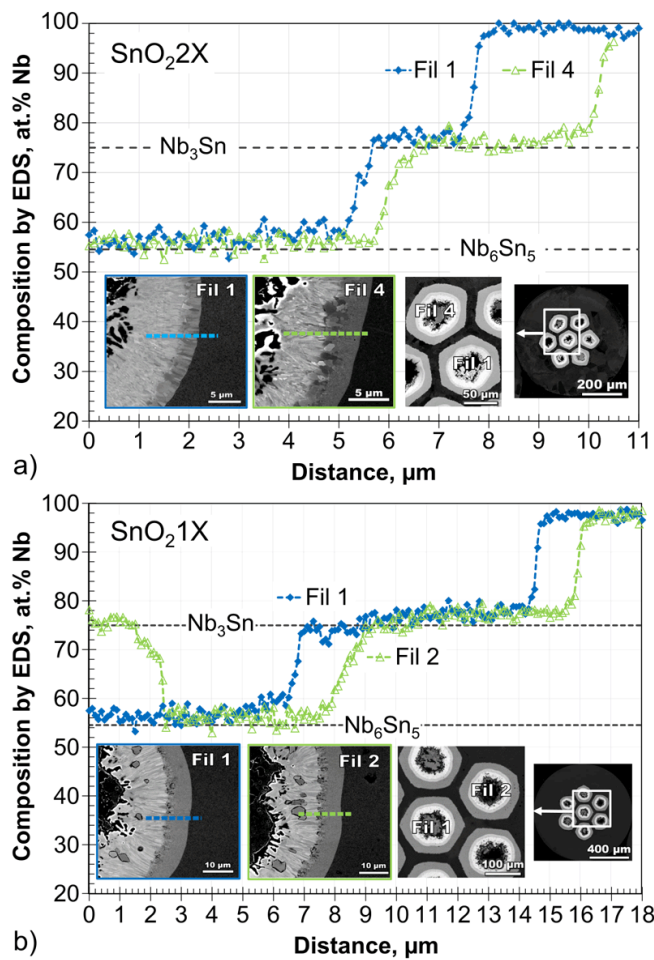


Figure 9. EDS analysis of 7-filament Zr/SnO₂ with a) Cu₅Sn₄:SnO₂ ratio “SnO₂2X” (strand in figure 5a) and b) “SnO₂1X” (strand in figure 5b), both heat treated for 300h/625°C. In a) the thicker “Fil 4” Nb₃Sn layer has a composition that is closer to stoichiometry than the central “Fil 1”, suggesting some Sn loss from this filament. In b) the Nb₆Sn₅ layer contains some large Nb₃Sn grains 1-3 μm in diameter

role in nucleating new A15 grains and in this way inhibit columnar growth.

3.1.4 Microchemical analysis. EDS analyses of filament layers from the SnO₂2X, and SnO₂1X samples shown in figure 5 are shown in figure 9a and 9b respectively. The composition of Nb₃Sn produced during the final reaction heat treatment is close to stoichiometric across most of the Nb₃Sn layer for Filament 4 in figure 9a (SnO₂2X) but is Sn-poor for the thinner A15 layer in the central filament (Filament 1) suggesting that there has been Sn loss through the tube to the surrounding Cu in this filament. The Sn composition for Filament 4 of the SnO₂2X wire eventually declines over the outer ~1 μm of the small-grain layer.

For the SnO₂1X sample, both filaments shown in figure 9b have a composition gradient across the A15 layer. An

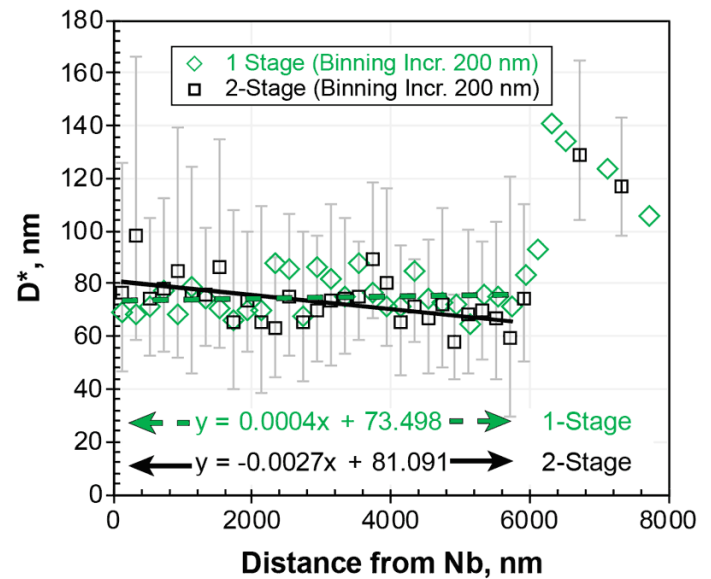


Figure 10. Area equivalent grain diameter (ln-normal) variation with distance from the unreacted Nb-1Zr interface for a 120 filament Nb1Zr+10SnO₂ composite heat treated with a single 300 h/630°C heat treatment (green) and a dual stage HT of 200 h/625°C + 100 h/650°C (black). The grain size is similar at the center of the layer (< 80 nm) but the 2-stage heat treatment produces an A15 grain size gradient across the layer). Least-square linear fits are shown for the data across the small grain layers.

interesting observation is that there are large Nb₃Sn grains that occur deep inside the Nb₆Sn₅ layer in filaments with the lower SnO₂ composition “SnO₂1X” wire, as is seen in figure 9b. For conventional PIT made with NbSn₂ powder precursor, Nb₆Sn₅ is an intermediate reaction phase that forms adjacent to the Nb tube during A15 layer growth and invariably decomposes to large-grain A15 by loss of Sn to the growing small-grain Nb₃Sn layer. The fact that a residual Nb₆Sn₅ layer is found at the interface indicates imperfect Sn diffusion into the filament tube that could have enabled further small-grain A15 layer growth.

3.1.5 Two-Stage Reaction Heat Treatment. In figure 10 we compare the Nb₃Sn area-equivalent grain diameters of the same 120 filament Nb1Zr+10SnO₂ composite heat treated with a single HT of 300 h at 630°C with a dual stage HT (200 h/625°C + 100 h/650°C) starting at a lower and finishing at a higher temperature. The dual-stage heat treatment with a final stage at 650°C did not greatly coarsen the grain size as compared to the single HT (the average grain size of < 80 nm for both strands is small for PIT Nb₃Sn) as is usually the case for Zr-free wires. The rationale for the second, higher temperature 650°C step is to drive more compositional uniformity across the A15 layer assuming that it is possible to establish a fine grain size at the lower temperature of the first stage. It seems that this has been quite successful because the initially formed grains furthest away from the unreacted Nb1Zr interface are small (~70 nm)

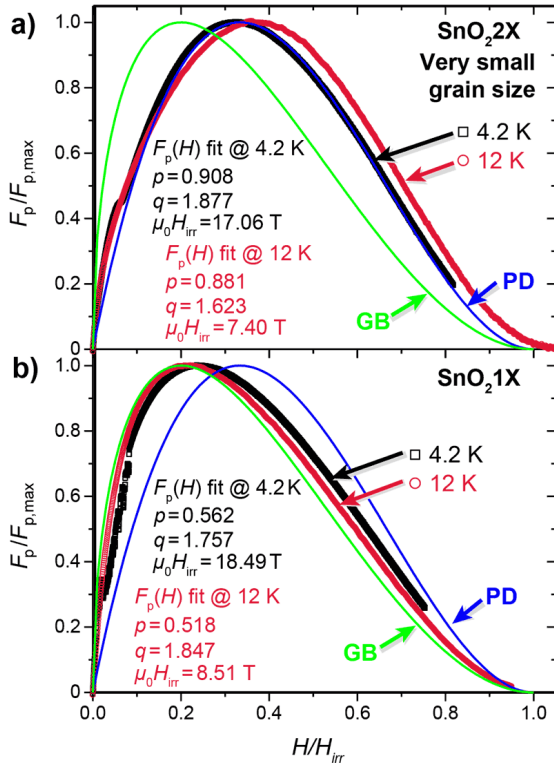


Figure 11. Normalized pinning force curves for a) composition “SnO₂2X” with small grains and b) composition “SnO₂1X” with larger grains at 4.2 K and 12 K. The ideal curves for grain boundary GB (green) and point defect PD (blue) pinning are also shown and the fitting parameters are reported.

and the final grains only slightly larger (~80 nm). This compares with a d^* of ~90 nm for a similarly heat treated (280h/625°C) Nb-Ta, Zr-free. PIT strand [11].

3.2 Magnetization results

Magnetization measurements at FSU enabled both 4.2 and 12 K properties to be obtained with derivation of the whole F_p curve at 4.2 and 12 K (shown in figure 11) for the samples whose microstructures are shown in figure 5. Higher SnO₂:Cu₅Sn₄ ratio “SnO₂2X” produced a very small Nb₃Sn grain size of ~30–40 nm, and pinning force curves peaking at higher reduced field with a curve shape approaching that expected for point defect (PD) pinning. In contrast, composition “SnO₂1X” produced a curve peaking at lower reduced field that more closely matched that for sparse grain boundary (GB) pinning, consistent with its larger grain size. If the precipitates in the “SnO₂2X” sample are also smaller they may be more effective as point pinning sites. However, fitting the pinning force curves with the generic relation $F_p/F_{p,max} \propto (H/H_{irr})^p (1 - H/H_{irr})^q$, $\mu_0 H_{irr}(4.2\text{ K})$ for composition “SnO₂2X” fell to 17.1 T compared with 18.5 T for composition “SnO₂1X”. Both values are smaller than would be expected from binary Zr-free wires. Also the p and q parameters are close to the values for GB pinning for “SnO₂1X” and close to the values for PD pinning for

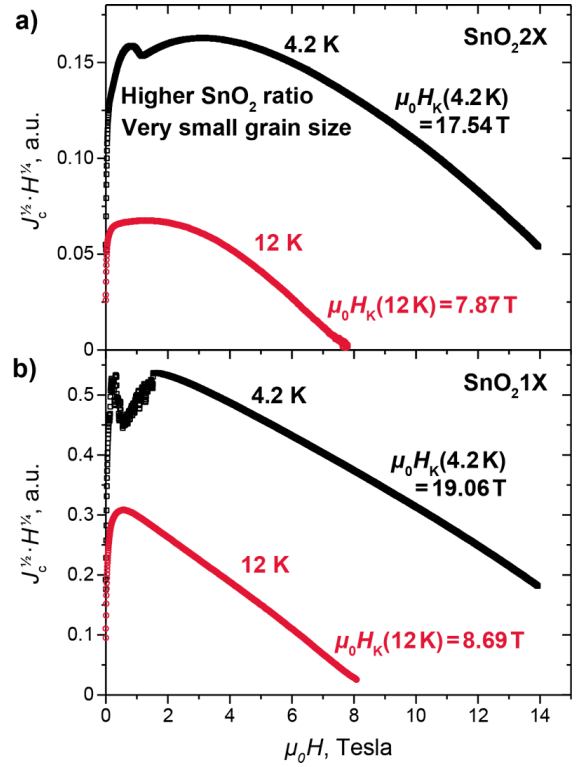


Figure 12. A comparison of the magnetization-derived Kramer plots for a) the high SnO₂:Cu₅Sn₄ composition “SnO₂2X” wire with smaller grains and b) composition “SnO₂1X” wire with larger grains and less ZrO₂ at 4.2 K and 12 K. The very small grain size microstructure (a) shows a clear deviation from the usual linearity of Kramer plots for Zr-free Nb₃Sn wires.

“SnO₂2X”.

Alternatively, using a two-contribution fit (see section 3.3), the relative contributions of PD and GB pinning were 89% PD, for composition “SnO₂2X”, but only 24% for “SnO₂1X”, consistent with the smaller precipitate density of the lower SnO₂:Cu₅Sn₄ core wire. The estimated small-grain-layer $J_{cm-layer}(4.2\text{ K}, 12\text{ T})$ for the high SnO₂:Cu₅Sn₄ composition “SnO₂2X” was ~4500 A/mm² (a high value for a Zr-free strand compared to our previous highest small-grain layer 12 T J_c value for a binary conventional PIT strand of 3300 A/mm² [32]). For composition “SnO₂1X” the estimated small-grain-layer $J_{cm-layer}(4.2\text{ K}, 12\text{ T})$ was about 2900 A/mm², thus showing no advantage.

In figure 12 we compare the magnetization-derived Kramer plots for the same samples as in figure 11. The Kramer plot should be linear if sparse grain boundaries are the only effective pinning centres. However, we do observe a distinctly non-linear Kramer plot in the ultra-small grain sized sample (composition “SnO₂2X”), which also had a markedly higher layer J_c .

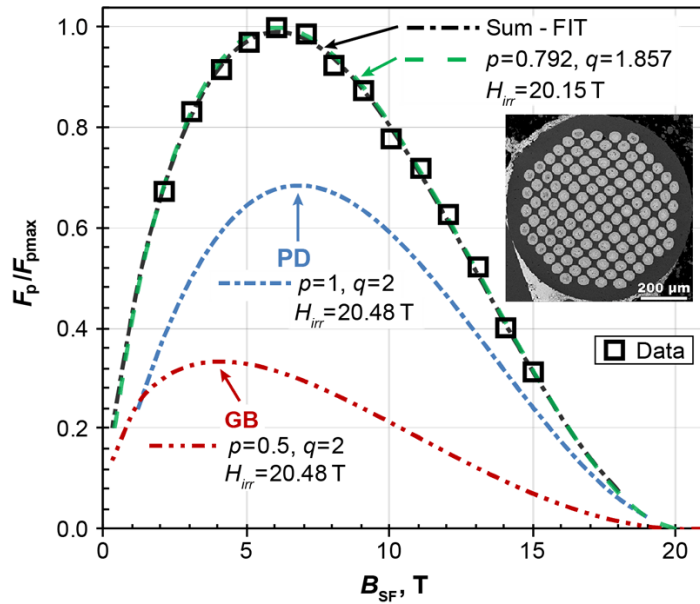


Figure 13. The normalized F_p is plotted as a function of the reduced field for Run # 3991: SnO₂(“S”)+Nb1Zr 300h@625°C: 120 Filament APC. The deconvolution into GB and PD pinning components shows that PD pinning dominates with 68% contribution to F_p . H_{irr} is found to be 20.48 T. When the exponents and H_{irr} are allowed to vary, the best fit to the data is shown by the dashed curve, which is very close to the summation curve.

3.3 Transport measurements

Billets L550 and L555 used the 120 filament PIT design with lower and higher SnO₂ ratios respectively. Consistent with the cross-sections, evidence of damage to the filaments appeared in the degraded n -values of ~ 5 . However, even though the transport critical currents are low due to poor filament quality, it was possible to measure their I_c from 15 T to very low fields, and thus determine the normalized flux-pinning curve, $f_p = F_p / F_{pmax}$, as a function of field. Measurements below 2 T are not shown, since they then include an additional contribution from the un-reacted Nb.

The I_c measurements were fitted by varying the parameters p and q and B_{c2} . An example is shown in figure 13 where the

normalized F_p is plotted as a function of the self-field corrected magnetic field, B_{SF} , for a strand from billet 550 reacted at 625°C for 300h. The best overall fit is obtained for $p=0.792$, $q=1.857$ and $B_{c2}=20.15$ T. The non-standard exponents p and q suggest that the pinning is not only from grain-boundary pinning ($p=0.5$, $q=2.0$), but also from an additional contribution, as has been observed in enhanced J_c Nb₃Sn wires with radiation-induced point defects within the grains [33]. These additional point pins shift the maximum of the pinning curve from $b=0.20$ to $b \sim 0.27$. Indeed, we can realistically deconvolute the data set of figure 13 into two components with fixed classical p and q values of $p=1$, $q=2$ for point defect pinning (PD) and $p=0.5$, $q=2$ for grain boundary (GB) pinning, where the point defect component dominates the total pinning, especially at higher fields where higher J_c is most desirable.

The analyses of the transport-current-tested strands are summarized in table II. The best pinning force fits were found for two-component PD + GB pinning for all the APC strands. The PD contribution ranged from 65% to 76%. Billet 555 had a higher proportion of SnO₂ powder in the core but had similar PD contributions to the other billet. In fact the lowest PD value was obtained from billet 555 strand that was reacted with a slow ramp rate of 10°C/h from room temperature to 630°C and held there for 100 h to reduce grain growth and thereby increase the GB pinning density. It appears that increasing the SnO₂ powder fraction in this composite does little to enhance the pinning, although the B_{c2} is ~ 2 T higher than that observed for billet 550.

4. Discussion

Despite the poor filament quality arising from low quality Nb1Zr tubes, the results reported here show that the PIT approach with Cu₅Sn₄ and SnO₂ is a viable method to deliver oxygen for the internal oxidation of Zr in Nb. By incorporating Cu as η -Cu₅Sn₄ in the powder core, the Cu can reduce the reaction temperature without blocking oxygen

Table II. Summary of J_c and n -values (12 T, 4.22 K, non-self-field corrected) and Pinning Force fits for PIT wires tested at BNL

Run No	Billet	HT	J_c (non-Cu A/mm ²)	n	p	q	$C\ddagger$	H_{irr} (T)	Two component fit:	H_{irr} (T)	% PD
3991	550	300h/625°C	109	3.3	0.79	1.86	9.44	20.15	PD ($p=1$) and GB ($p=0.5$)	20.48	68%
3993	550	200h/650°C	162	3.5	0.72	1.42	10.09	18.82	PD ($p=1$) and GB ($p=0.5$)	21.08	69%
3994	550	200h/650°C	182	3.9	0.80	1.67	13.11	19.74	PD ($p=1$) and GB ($p=0.5$)	20.80	76%
4051	555 [‡]	48h/540°C, 200h/632 °C	89	2.6	0.78	1.66	5.14	21.79	PD ($p=1$) and GB ($p=0.5$)	23.30	71%
4133	555 [‡]	10°C/h + 100h/630°C	42	2.6	0.75	1.65	3.06	21.40	PD ($p=1$) and GB ($p=0.5$)	22.79	65%

[†] = slope of the Kramer plot of F_p (A·T/mm²) vs. $b^p \cdot (1-b)^q$ [‡] = higher proportion of SnO₂ powder in the core

diffusion as was the case with earlier attempts at internal oxidation [21]. Recent work by Xu *et al.* [34] has indicated that Nb-Sn intermetallics may still impede oxygen diffusion from the core requiring more SnO₂ and further HT modification to overcome this issue.

Both magnetization and transport measurements on the SupraMagnetics strands showed that this approach of introducing ZrO₂ precipitates and refining the grain size from 90 nm in Zr-free wires to less than 40 nm shifts the peak in the pinning force curve from about $b \sim 0.2$ to as high as 0.35 in figure 11, as is expected from a large point pinning component. These results are similar to the very small grain size (20-50 nm diameter) films [35] that produced a shift in the peak of $F_p(H)$ to almost $0.4H_{irr}$ in thin films (Nb sputtered onto a bronze substrate and then reacted). Using transport J_c barrel measurements, the F_p curves could be deconvoluted into a dominant PD contribution (65%) to F_p that is similar to the point defect irradiation effects observed by Baumgartner *et al.* [33]. An even larger 89% PD contribution was estimated by magnetic measurements on the 30-45 nm grain size sample.

For high field magnet conductor use there is still some uncertainty as to the potential of this approach as there was significant suppression of the Kramer extrapolated fields for all samples. Normally speaking the $\mu_0 H_{c2}$ of binary Nb₃Sn is 23-24 T [36], as compared to the ~ 17.5 -22 T values found here (which are similar to the values of 20.5 and 21.3 T obtained by Xu *et al.* for their Nb1Zr APC [22]). The depression was notably larger for the higher SnO₂ 7-filament sample with the very small A15 grain size. Whether the degradation of H_{irr} is due to Zr or perhaps to strain induced by ZrO₂ within the A15 grains is not yet clear but this is something that needs verification because a high critical field is essential for reaching high critical currents at fields above 16 T. All modern Nb₃Sn wire use Ta or Ti or a combination of Nb and Ti dopants to increase their high-field performance by increasing H_{c2} [37] and verification of the effectiveness of ZrO₂ using Nb alloys containing Ti or Ta to enhance the upper critical field will be needed.

5. Conclusions

1. A viable route to an APC (artificial pinning centre) Nb₃Sn has been demonstrated in multifilamentary PIT strand by internal oxidation of Nb1Zr tubes using a core powder mixture of η -phase Cu₅Sn₄ powder and SnO₂. However, the volume of small-grain Nb₃Sn produced in these demonstration samples was only ~ 18 -25% of that for modern accelerator-quality PIT Nb₃Sn, so significant improvements in package efficiency and heat treatment optimization will be required to make this process

competitive.

2. Cu₅Sn₄ does not appear to interfere with the diffusion of oxygen from SnO₂/ Cu₅Sn₄ powder mixtures into Nb1Zr filament tubes. This suggests that only small modifications to existing internal Sn and PIT approaches will be necessary to fully prove out this method of enhancing vortex pinning in Nb₃Sn, providing that pure Cu does not sit between the Sn and Nb1Zr during the reaction step.
3. A shift in the peak of the pinning force curve to higher reduced fields was similar to that observed for APC thin films and recent radiation experiments. However, as in recent work by Xu *et al.* [22], the Kramer fields were significantly depressed from that found in the best Zr-free binary conductors.
4. The pinning force curves can be deconvoluted into contributions from point and grain boundary pinning with point pinning supplying up to 89% of the pinning force for the APC strands in the most favourable case. The estimated Nb₃Sn small-grain layer J_{cm} (12 T, 4.2 K) was $\sim 36\%$ higher than that previously reported for a conventionally processed binary PIT.
5. The applicability of this technique to optimizing high field performance still needs to be demonstrated using alloys incorporating Ti and/or Ta to increase H_{c2} .
6. Better tube quality that maintains its integrity through the drawing cycle so that η phase is not lost when melted and an understanding of why some filaments are left with partial Nb₃Sn reactions and thick Nb₆Sn₅ layers should yield much better critical current values. The issue of microstructural gradients will also have to be addressed.

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